

## ABSTRACT

A basting apparatus including a rack supporting a basting pan, a grill, and a rotisserie having a spit and means for rotating. The rack is dimensioned to fit between the surface of the grill and the rotisserie and includes a grid and a frame. The basting pan is supported by the rack at an elevation so that when the pan is filled with basting fluid, the surface of the basting fluid comes in contact with the food on the rotisserie. The rack is adjustable to accommodate various sized pans and grills. A heating element is also provided that is located in the rear of the grill in relation to the rotisserie.